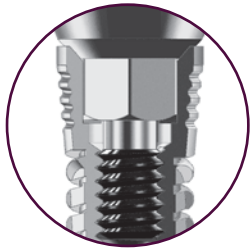


THREE IMPLANTS
TWO CONNECTIONS
TWO PROVEN SURFACES

SpiralTech implants all feature a proven SL or RBM surface. Applied in a controlled environment, the RBM process uniformly micro-roughens the implant to maximize surface area bone cell growth and adhesion. Filler layers that could later form debris or compromise healing are omitted.



HEX CONNECTION



CONICAL HEX CONNECTION

OUR COMPANY



Founded in 2012, SpiralTech was created to fill a void in the dental implant world—simplified treatment paired with the best technologies and customer service.

SpiralTech's goal is to provide doctors of all experience levels with innovatively designed implants and accessories while providing all of the necessary educations and services.

Ultimately, our mission is to enhance the doctor-patient experience.

The ESi implant product line is the first step in what we see as a continuous journey towards clinical excellence.

HEADQUARTERS



875 N. Michigan Avenue, Suite 3106
Chicago, IL 60611
312-440-7777

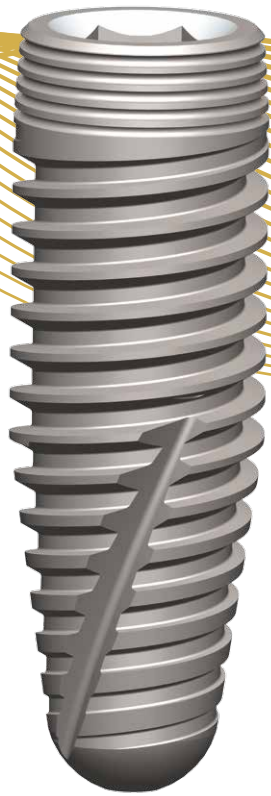
Toll free (888) 991-7997

ISO 13485:2003
EC Certificate US15/842415
ImplantOverviewBrochure-V10-9.29.17

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Implant Overview





Premium

Premium implant is a dependable, conventionally designed implant. While it can be used in all clinical situations, its conservative threads are best suited for healed ridges with or without previous grafting. It is excellent for working in Type I & II bone.



ESi™

The Innovative design of the ESi implant is doctor friendly, efficient and revolutionary. It is designed to ease your implant placement. The self-tapping threads allow for retracting and repositioning to the desired location. The ESi is great for beginning and experienced surgeons alike.



Ultimate

The Ultimate implant is designed for high initial stability—even in soft bone. It is an excellent implant for immediate placement and/or immediate loading. Due to its innovative design, the Ultimate can be redirected during placement to the ideal position.